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ELECTRONICALLY FILED ON ~~05~~ FEBRUARY 2007.

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of inventor(s):  
**Michel Luc Cote et al.**

Application No. **10/799,073**

Confirmation No. **8538**

Filing Date: **12 March 2004**

Title: **Design and Layout of Phase Shifting  
Photolithographic Masks**

Group Art Unit: 1756

Examiner: Stephen D. Rosasco

**CUSTOMER NO. 30437**

**MAIL STOP AMENDMENT**

Commissioner for Patents

P.O. Box 1450

Alexandria, VA 22313-1450

**AMENDMENT AND RESPONSE TO RESTRICTION REQUIREMENT**

Sir:

In response to the Office Action mailed 10 January 2007, Applicants request the following amendments in the above-referenced application:

**Amendments to the Claims** are reflected in the listing of claims which begins on page 2 of this paper.

**Remarks** begin on page 5 of this paper.

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